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Toward an Understanding of Surface Layer Formation, Growth, and Transformation at the Glass–Fluid Interface

J. Hopf, J.R. Eskelsen, M. Chiu, A.V. Ievlev, O.S. Ovchinnikova, D. Leonard, E.M. Pierce

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## ACCEPTED MANUSCRIPT

## TOWARD AN UNDERSTANDING OF SURFACE LAYER FORMATION, GROWTH, AND TRANSFORMATION AT THE GLASS-FLUID INTERFACE

Authors: J Hopf<sup>1‡</sup>, JR Eskelsen<sup>1‡</sup>, M Chiu<sup>1</sup>, AV Ievlev<sup>2</sup>, OS Ovchinnikova<sup>2</sup>, D Leonard<sup>3</sup>, and EM Pierce<sup>1\*</sup>

Affiliations:

<sup>1</sup>Environmental Sciences Division, Oak Ridge National Laboratory (USA);

<sup>2</sup>Center for Nanophase Material Sciences, Oak Ridge National Laboratory (USA);

<sup>3</sup>Material Science and Technology, Oak Ridge National Laboratory (USA);

\*Corresponding Author: Email: pierceem@ornl.gov, Phone: (865) 574-9968

<sup>‡</sup>J Hopf and J Eskelsen contributed equally to this work and are represented here as co-first authors.

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